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## INTERNATIONAL JOURNALS PUBLICATIONS

2020	
1	J.Ajayan, <b>D.Nirmal</b> , P.Mohankumar, M.Saravanan, M.Jagadesh and L.Arivazhagan, "A review of photovoltaic performance of organic/inorganic solar cells for future renewable and sustainable energy technologies" <i>Superlattices and Microstructures</i> , <a href="https://doi.org/10.1016/j.spmi.2020.106549">https://doi.org/ 10.1016/j.spmi.2020. 106549</a> , (2020) pp 1-53 ( <b>Impact Factor:2.385</b> ).
2	K.Husna Hamza and <b>D. Nirmal</b> , " A review of GaN HEMT broadband power amplifiers", <i>International Journal of Electronics and Communications (AEU)</i> , Vol 116, (2020) DOI: 10.1016/j.aeue.2019.153040 ( <b>Impact Factor:2.853</b> )
3	D.Godfrey, <b>D.Nirmal</b> , L. Arivazhagan, R.Rathes kannan, P.Issac Nelson, S.Rajesh, B.Vidhya and N.Mohankumar "A novel ZnPc nanorod derived piezoelectric nanogenerator for energy harvesting " <i>Physica E Low-Dimensional Systems and Nanostructures Vol.118 (2020) (Impact Factor:3.176)</i> .
4	S.Angen, J. Grace jency and <b>D.Nirmal</b> , " A wearable energy storage capacitor using graphene oxide and magnesuim oxide as electrodes" <i>Physica E Low-Dimensional Systems and Nanostructures 115 (2020) (Impact Factor:3.176)</i> .
5	A.S. Augustine Fletcher, <b>D. Nirmal</b> , L. Arivazhagan, J. Ajayan and Varghese, A, " Enhancement of Johnson figure of merit in III-V HEMT combined with discrete field plate and AlGa <sub>N</sub> blocking layer", <i>International Journal of RF and Microwave Computer-Aided Engineering</i> , vol 30, Issue 2(2020). ( <b>Impact Factor:1.472</b> )
2019	
6	Rani, C.S.H., Bagan, K.B., <b>Nirmal, D</b> and Roach, R.S., " Enhancement of Performance in TFET by Reducing High-K Dielectric Length and Drain Electrode Thickness" <i>Silicon</i> , doi:10.1007/s12633-019-00328-w (2019) ( <b>Impact Factor:1.210</b> ).
7	M.Manikandan, <b>D.Nirmal</b> , J.Ajayan, P.Mohankumar, P.Prajoon and L.Arivazhagan "A review of blue light emitting diodes for future solid state lighting and visible light communication applications", <i>Superlattices and Microstructures</i> 136 (2019). <a href="https://doi.org/10.1016/j.spmi.2019.106294">https://doi.org/ 10.1016/j.spmi. 2019.106294</a> , ( <b>Impact Factor:2.385</b> ).
8	J.Ajayan, <b>D.Nirmal</b> , Dheena Kurian, P.Mohankumar, L.Arivazhagan , A.S. Augustine Fletcher ,T.D.Subash and M.Saravanan" Investigation of impact of gate underlap/overlap on the analog/RF performance of composite channel double gate MOSFETs" <i>Journal of Vacuum Science &amp; Technology B</i> <b>37</b> , 062201 (2019); <a href="https://doi.org/10.1116/1.5116199">https://doi.org/10.1116/1.5116199</a> ( <b>Impact Factor:1.351</b> ).
9	J.Ajayan, <b>D.Nirmal</b> , P.Mohankumar, Dheena Kurian, A.S. Augustine Fletcher , L.Arivazhan and B.Santhosh kumar" GaAs metamorphic high electron mobility transistors for future deep space-biomedical-military and communication system applications: A review" <i>Microelectronics journal</i> , <a href="https://doi.org/10.1016/j.mejo.2019.104604">https://doi.org/10.1016/j.mejo. 2019.104604</a> Vol 108, (2019) ( <b>Impact Factor:1.284</b> ).
10	J.Ajayan, <b>D.Nirmal</b> , P.Mohankumar, and L.Arivazhan, " Investigation of Impact of Passivation Materials on the DC/RF Performances of InP-HEMTs for Terahertz Sensing and Imaging" <i>Silicon</i> , doi.org/10.1007/s12633-019-00226-1 (2019) pp 1-6 ( <b>Impact Factor:1.210</b> ).
11	L. Arivazhagan , , <b>D. Nirmal</b> , D.Godfrey, J. Ajayan , P.Prajoon A.S. Augustine Fletcher, A.Amir Anton Jone and J.S.Raj Kumar, "Improved RF and DC performance in AlGa <sub>N</sub> /Ga <sub>N</sub> HEMT by P-type doping in Ga <sub>N</sub> buffer for millimetre-wave applications", <i>International Journal of Electronics and Communications (AEU)</i> , Vol 108, (2019) Pg 189-194. ( <b>Impact Factor:2.853</b> )
12	A.S. Augustine Fletcher, <b>D. Nirmal</b> , J. Ajayan and L. Arivazhagan, "Analysis of AlGa <sub>N</sub> /Ga <sub>N</sub> HEMT using discrete field plate technique for high power and high frequency applications", <i>International Journal of Electronics and Communications (AEU)</i> , Vol 99, (2019) Pg 325-330. ( <b>Impact Factor:2.853</b> )
13	Suresh Subramanian, B. Sundarambal and <b>D. Nirmal</b> , "Investigation on Simulation-Based Specific Absorption Rate in Ultra-Wideband Antenna for Breast Cancer Detection", <i>IEEE Sensors Journal</i> , Vol 18 No.24, 20 Dec 2018, ( <b>Impact Factor:2.617</b> )
14	D. Gracia, <b>D. Nirmal</b> and D. Jackuline Moni, "Impact of Leakage Current in Germanium Channel based DMDG TFET using Drain-gate underlap technique", <i>International Journal of Electronics and Communications (AEU)</i> , Vol 96, (2019) Pg 164-169. ( <b>Impact Factor:2.853</b> )
15	P. Vanitha, T.S. Arun Samuel and <b>D. Nirmal</b> , "A New 2D Mathematical Modeling of Surrounding Gate Triple material Tunnel FET using Halo Engineering for Enhanced Drain Current", <i>International Journal of Electronics and Communications (AEU)</i> , Vol 99, (2019) Pg 34-39. ( <b>Impact Factor: 2.115</b> )
2018	
16	J.Ajayan, T.Ravichandran, P.Mohankumar, P.Prajoon, J.Charles Pravin and D.Nirmal, " Investigation of DC and RF Performance of Novel MOSHEMT on Silicon Substrate for Future Submillimeter Wave Applications" <i>Semiconductors</i> , vol. 52,No.16,(2018) pp 1191-1997 ( <b>Impact Factor:0.672</b> ).

17	R.Ratheskumar,P.Isaac Nelson, S.Rajesh, T.Ponmudi selvi, A.Mohan , B.Vidhya, <b>D.Nirmal</b> and Arivazhan “ Curtailed recombination rate and fast carrier transport in ZnPc/Ga As/ Zn Pc Stacked hybrid structure ” <i>Optical Materials</i> , vol. 85,(2018) pp 287-294.( <b>Impact Factor:2.320</b> ).
18	D.Gracia , <b>D.Nirmal</b> and D.Jackuline Moni, “ Impact of leakage current in germanium channel based DMDG TFET using drain- gate underlap technique” ” <i>International Journal of Electronics and Communications (AEÜ)</i> , vol.96,(2018) pp 164-169.( <b>Impact Factor:2.115</b> ).
19	J. Ajayan , <b>D. Nirmal</b> , T.Revichandran, P.Mohankumar, P. Prajoon, L. Arivazhagan , Chandran Kumar Sarkar “ InP high electron mobility transistors for submillimeter wave and terahertz frequency applications: A review ” <i>International Journal of Electronics and Communications (AEÜ)</i> , vol.94,(2018) pp 199-214.( <b>Impact Factor:2.115</b> ).
20	J. Hengsteler, P. Prajoon, <b>D. Nirmal</b> , “ Analysis of High Efficiency InGaN Multiple-Quantum-Well Light-Emitting-Diodes Using InGaN Step-Graded Barriers” <i>Journal of Nanoelectronics and Optoelectronics</i> , vol.13,(2018) pp 939-943.( <b>Impact Factor:1.019</b> ).
21	J. Ajayan , T.Revichandran, P.Mohankumar, P. Prajoon, J. Charles Pravin, <b>D. Nirmal</b> , “ Investigation of breakdown performance in $L_g = 20$ nm novel asymmetric InP HEMTs for future high-speed high-power applications” <i>Journal of Computational Electronics</i> , vol.17,(2018) pp 265-272.( <b>Impact Factor:1.431</b> ).
22	J. Ajayan , T.Revichandran, P.Mohankumar, P. Prajoon, J. Charles Pravin, <b>D. Nirmal</b> , “ Investigation of DC-RF and breakdown behaviour in $L_g = 20$ nm novel asymmetric GaAs MHEMTs for future submillimetre wave applications” <i>International Journal of Electronics and Communications (AEÜ)</i> , vol.84,(2018) pp 387-393.( <b>Impact Factor:2.115</b> ).
23	J. charles pravin, p. prajoon, flavia princess nesamania, p. senthil kumar, <b>D. Nirmal</b> , and G.sriresh,“ Nanoscale High-k Dielectrics for Junctionless Nanowire Transistor for Drain Current Analysis” ” <i>Journal of ELECTRONIC MATERIALS</i> “ <a href="https://doi.org/10.1007/s11664-018-6075-2">https://doi.org/10.1007/s11664-018-6075-2</a> ( <b>Impact factor: 1.676</b> )
24	P. Prajoon , M. Anuja Menokey , J. Charles Pravin , J. Ajayan , S. Rajesh , <b>D. Nirmal</b> , “ Investigation of efficiency enhancement in InGaN MQW LED with compositionally step graded GaN/InAlN/GaN multi-layer barrier” ” <i>Superlattices and Microstructures</i> DOI:10.1016/j.spmi.2018.02.008 ( <b>Impact factor: 2.123</b> ).
<b>2017</b>	
25	<b>D. Nirmal</b> , L. Arivazhagan, A.S.Augustine Fletcher, J. Ajayan, P. Prajoon “ Current collapse modeling in AlGaIn/GaN HEMT using small signal equivalent circuit for high power application” ” <i>Superlattices and Microstructures</i> <a href="https://doi.org/10.1016/j.spmi.2017.12.027">https://doi.org/10.1016/j.spmi.2017.12.027</a> ( <b>Impact factor: 2.123</b> )
26	J. Ajayan , <b>D. Nirmal</b> , P. Prajoon and J. Charles Pravin “Analysis of nanometer-scale InGaAs/InAs/InGaAs composite channel MOSFETs using high-K dielectrics for high speed applications” <i>International Journal of Electronics and Communications (AEÜ)</i> , vol.79,(2017)pp 151-157( <b>Impact Factor:1.147</b> ).
27	A.S. Augustine Fletcher, and <b>D.Nirmal</b> , “ A survey of Gallium Nitride HEMT for RF and highpower applications” ” <i>Superlattices and Microstructures</i> DOI: 10.1016/j.spmi.2017.05.042( <b>Impact factor: 2.123</b> )
28	P. Murugapandian, S.Ravimaran, J.William, J Ajayan and <b>D.Nirmal</b> , “ DC and microwave characteristics of 20 nm T-gate InAlN/GaN high electron mobility transistor for high power RF applications” ” <i>Superlattices and Microstructures</i> DOI: 10.1016/j.spmi.2017.05.060 ( <b>Impact factor: 2.123</b> )
29	D.Gracia , <b>D.Nirmal</b> and A. Nisha Justeena, “ Investigation of Ge based Double Gate Dual Metal Tunnel FET Novel Architecture using Various Hetero dielectric Materials” ” <i>Superlattices and Microstructures</i> DOI: 10.1016/j.spmi.2017.04.045 ( <b>Impact factor: 2.123</b> )
30	J. Ajayan and <b>D. Nirmal</b> , “20 nm In <sub>0.75</sub> Ga <sub>0.25</sub> As channel-based HEMTs on Inp/GaAs substrates for future THz applications” <i>Journal of semiconductors</i> , vol.38,No.4(2017)pp 1-6.
31	Charles Pravin J, <b>D.Nirmal</b> , Prajoon P , N.Mohan kumar and Ajayan J, “Investigation of 6T SRAM memory circuit using high-k dielectrics based nano scale junctionless transistor” ” <i>Superlattices and Microstructures</i> DOI: 10.1016/j.spmi.2017.03.012( <b>Impact factor: 2.117</b> )
<b>2016</b>	
32	J. Ajayan and <b>D. Nirmal</b> , “20 nm high performance enhancement mode InP HEMT with heavily doped S/D regions for future THz applications ” <i>Superlattices and Microstructures</i> DOI: 10.1016/j.spmi.2016.10.011 ( <b>Impact factor: 2.117</b> )
33	P.Prajoon, <b>D. Nirmal</b> , Anuja Menokey and J.Charlespravin, “Temperature dependant efficiency droop analysis of In GaN MQW light emitting diode with modified ABC model.”, <i>J Comput Electron</i> , Vol 16 (2016) pp 1511–1520. ( <b>Impact factor – 1.104</b> ).
34	J. Ajayan and <b>D. Nirmal</b> , “20-nm enhancement-mode metamorphic GaAs HEMT with highly doped InGaAs source/drain regions for high frequency applications” <i>International Journal of Electronics</i> DOI: 10.1080/00207217.2016.1218066 ( <b>Impact factor:0.729</b> )

35	J. Ajayan and <b>D. Nirmal</b> , “20-nm T-gate composite channel enhancement-mode metamorphic HEMT on GaAs substrates for future THz applications” <i>J Comput Electron</i> Vol 16(2016), pp 1291–1296. <b>(Impact factor:1.104)</b>
36	Charles Pravin J, <b>D.Nirmal</b> , Prajoon P and Anuja Menokey M., “A New Drain Current Model for Dual Metal Junctionless Transistor for Enhanced Digital Circuit Performance” <b>IEEE</b> Trans. Electron Devices, VOL. 63, NO. 9(2016) pp 3782-3789. <b>(Impact Factor – 2.207)</b> .
37	Prajoon P, <b>D. Nirmal</b> , AnujaMenokey M, J Charles Pravin “Efficiency Enhancement of InGaN MQW LED Using Compositionally Step Graded InGaN Barrier on SiC Substrate” <b>IEEE J. Display Technology</b> , DOI: 10.1109/JDT.2016.2570814, (2016) 1117 - 1121. <b>(Impact Factor – 1.925)</b> .
38	P.Prajoon, <b>D .Nirmal</b> , AnujaMenokey and J.Charlespravin, “A Modified ABC Model in InGaN MQW LED Using Compositionally Step Graded Alternating Barrier for Efficiency Improvement”, <i>Superlattices and Microstructures</i> , 96 (2016) 155-163. <b>(Impact factor – 2.097)</b> .
39	J. Charles Pravin, <b>D. Nirmal</b> , P. Prajoon and J. Ajayan, “Implementation of nanoscale circuits using dual metal gate engineered Nanowire MOSFET with high-k dielectrics for low power applications” <i>Physica E</i> 83 (2016) 95–100. <b>(Impact Factor: 2.00)</b> .

#### INTERNATIONAL CONFERENCE PUBLICATIONS

<b>2020</b>	
1	L. Arivazhagan, Anwar Jarndal, Subhash Chander, Godfrey D, Raj Kumar J S, S Bhagyalakshmi, Pavan Kumar Reddy and <b>D.Nirmal</b> , “Self-Heating Analysis of GaN-HEMT for Various Ambient Temperature and Substrate Thickness” IEEE Conference Proceedings on 2020 5th International Conference on Devices, Circuits and Systems, ICDCS20, Coimbatore, India, 5 <sup>th</sup> -6 <sup>th</sup> March 2020.
2	Husna Hamza K, <b>D.Nirmal</b> and L. Arivazhagan, “Impact of AlGaIn Back Barrier in AlGaIn/GaN HEMT on GaN substrate” IEEE Conference Proceedings on 2020 5th International Conference on Devices, Circuits and Systems, ICDCS20, Coimbatore, India, 5 <sup>th</sup> -6 <sup>th</sup> March 2020.
3	Godfrey D, <b>D.Nirmal</b> , L. Arivazhagan, Brigis Roy, Yu-Lin Chen, Tien-Han Yu, Wen-Kuan Yeh and Godwinraj D, “Investigation of AlGaIn/GaN HEMT Breakdown analysis with Source field plate length for High power applications” IEEE Conference Proceedings on 2020 5th International Conference on Devices, Circuits and Systems, ICDCS20, Coimbatore, India, 5 <sup>th</sup> -6 <sup>th</sup> March 2020.
<b>2019</b>	
4	Arivazhagan.L, <b>D.Nirmal</b> , Ajayan.J, Rajkumar.J.S, Godfry.D, Bhagya.S, “Modeling of self-heating for AlGaIn/GaN HEMT with thermal conductivity degradation effect” AIP Conference Proceedings 2nd International Conference on Material Science, Smart Structures and Applications, ICMSS 2019, Erode, India, Volume 2201, 17 December 2019.
5	Arivazhagan.L, <b>D.Nirmal</b> , Ajayan.J, Rajkumar.J.S, Godfry.D, Bhagya.S, “Enhancement of drain current in AlGaIn/GaN HEMT using AlN passivation” AIP Conference Proceedings 2nd International Conference on Material Science, Smart Structures and Applications, ICMSS 2019, Erode, India, Volume 2201, 17 December 2019.
<b>2018</b>	
6	Moni.D.J, Anucia.A.J, D.Gracia, <b>D.Nirmal</b> , “Performance Analysis of GaSb/InAs Tunnel FET for Low Power Applications” IEEE International Conference on Devices, Circuits and Systems, ICDCS 2018; Karunya University, Coimbatore, pp- 335-338.
7	Pandit.P.P, Arivazhagan.L, <b>D.Nirmal</b> , Prajoon.P, Ajayan.J, Rajkumar.J.S, “DC Performance analysis of AlGaIn/GaN HEMT for future High power applications” IEEE International Conference on Devices, Circuits and Systems, ICDCS 2018; Karunya University, Coimbatore, pp- 313-318.
<b>2017</b>	
8	Nisha Justeena.A , <b>D.Nirmal</b> , Gracia.D,”Design and Analysis of Tunnel FET using High K Dielectric Materials” IEEE International Conference on Innovations in Electrical,Electronics, Instrumentation and Media technology (ICIEEIMT’17), Karunya University, Coimbatore, pp-177-180, 4 March-2017.
9	Pratik.P.Pandi, Grace Jency, J,Monic Babu, Kishore Kumar, <b>D.Nirmal</b> ,”Fabrication of Ultra Flexible Super Capacitor using PVdF” IEEE International Conference on Innovations in Electrical,Electronics, Instrumentation and Media technology (ICIEEIMT’17), Karunya University, Coimbatore, pp-98-102, 4 March-2017.

10	Subash Chander, Ajay, <b>D.Nirmal</b> , Mridula Gupta, "30nm Normally Off Enhancement Mode AlGa <sub>N</sub> /Ga <sub>N</sub> HEMT on SiC Substrate for Future High Speed Nanoscale Power applications" " IEEE International Conference on Innovations in Electrical, Electronics, Instrumentation and Media technology (ICIEEIMT'17), Karunya University, Coimbatore, pp-293-296, 4 March-2017.
<b>2016</b>	
11	AnujaMenokey, <b>D Nirmal</b> , Prajoon P, J Charles Pravin, "Green InGa <sub>N</sub> /Ga <sub>N</sub> LEDs with n-GaN Interlayer for efficiency droop improvement" International Conference on Devices, Circuits and Systems (ICDCS'16), Karunya University, Coimbatore, pp-216-219, 3 March-2016.
12	Charles Pravin., <b>D.Nirmal</b> , PrajoonP., Altrin Sharma., AnujaMenokey M "Impact of Gate Length on the Performance of a Junctionless Dual Metal Transistor with High-k dielectrics", International Conference on Devices, Circuits and Systems (ICDCS'16), Karunya University, Coimbatore, pp-291-294, 3 March-2016.